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<b>PTO TRANSMITTAL FORM</b> JAN 28 2005 (to be used for all correspondence after initial filing)	Application Number	10/815,994	
	Filing Date	March 31, 2004	
	First Named Inventor	Chung J. Lee	
	Art Unit	2827	
	Examiner Name		
Total Number of Pages in This Submission	9+	Attorney Docket Number	DSI 303

ENCLOSURES (Check all that apply)		
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Firm Name	Alleman Hall McCoy Russell & Tuttle LLP		
Signature	<i>M. Matthews Hall</i>		
Printed name	M. Matthews Hall		
Date	January 26, 2005	Reg. No.	43,653

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This collection of information is required by 37 CFR 1.5. The information is required to obtain or retain a benefit by the public which is to file (and by the USPTO to process) an application. Confidentiality is governed by 35 U.S.C. 122 and 37 CFR 1.11 and 1.14. This collection is estimated to 2 hours to complete, including gathering, preparing, and submitting the completed application form to the USPTO. Time will vary depending upon the individual case. Any comments on the amount of time you require to complete this form and/or suggestions for reducing this burden, should be sent to the Chief Information Officer, U.S. Patent and Trademark Office, U.S. Department of Commerce, P.O. Box 1450, Alexandria, VA 22313-1450. DO NOT SEND FEES OR COMPLETED FORMS TO THIS ADDRESS. SEND TO: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

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In re Application of:

Date: January 26, 2005

CHUNG J. LEE and ATUL KUMAR

Serial No. : 10/815,994

Group Art Unit 2827

Filed : March 31, 2004

For : SINGLE AND DUAL DAMASCENE TECHNIQUES  
UTILIZING COMPOSITE POLYMER DIELECTRIC FILM

Mail Stop AMENDMENT  
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Sir:

**SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT**  
**UNDER 37 C.F.R. §§ 1.56, 1.97, and 1.98**

Applicants are submitting this Supplemental Information Disclosure Statement pursuant to 37 C.F.R. §§ 1.56, 1.97, and 1.98 to disclose to the U.S. Patent and Trademark Office the patents, publications, applications, and/or other references listed on the enclosed, completed PTO-1449 form(s). The filing of this Supplemental Information Disclosure Statement should not be construed as a representation that a search has been made or as an admission that the listed references are prior art for this application. Applicants respectfully request that the listed references be expressly considered during prosecution of the application, and that the references be made of record therein and appear among the "references cited" on any patents issuing therefrom.

## CONTENT OF DISCLOSURE

This Supplemental Information Disclosure Statement includes (1) six pages of PTO-1449 forms, and (2) a legible copy of each foreign and non-patent reference, if any, listed on the form(s). However, because this application was filed on or after July 1, 2003, no copies of U.S. patents or published U.S. patent applications are included.

## TIMING OF DISCLOSURE / FEE INFORMATION

This Supplemental Information Disclosure Statement is being filed, to the best of the undersigned's knowledge, either (1) before the mailing of a first Office action on the merits, or (2) before the mailing of a first Office action after the filing of a request for continued examination under 37 C.F.R. § 1.114. Therefore, in accordance with 37 C.F.R. § 1.97(b), no fee or statement under 37 C.F.R. § 1.97(e) is required.

Please contact the undersigned with any questions or comments regarding this Supplemental Information Disclosure Statement.

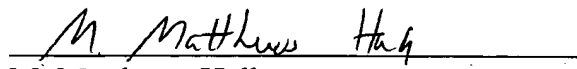
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Respectfully submitted,

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FORM PTO-1449 INFORMATION DISCLOSURE CITATION IN TRADE APPLICATION		DOCKET NUMBER DSI 303		APPLICATION NUMBER 10/816,179		
		APPLICANTS Chung J. Lee and Atul Kumar				
		FILING DATE March 31, 2004		GROUP ART UNIT 1763		
U.S. PATENT DOCUMENTS						
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FIL. DATE IF APPROP.
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	3,349,045	10/24/1967	Gilch			
	3,379,803	04/23/1968	Tittmann et al.			
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	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION YES NO
	EP 0 349 032 A2	01/03/1990	EPO			
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	WO 97/15951	05/01/1997	WIPO			
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	2003-0198578	10/23/2003	Lee			
	2003-0196680	10/23/2003	Lee			
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